

Appl. No. 10/698,143  
Amdt. dated August 30, 2005  
Reply to Office action of June 14, 2005

In the Claims:

Claims 1-26 are canceled. New claims 27-29 are added.

1-26. (canceled)

27. (new) A method for fabricating a reflective type reflector plate of a reflective liquid crystal display, the method comprising the steps of:

preparing a glass substrate with thin film transistors built on a surface of the glass substrate;

forming transparent electrodes over the glass substrate after the thin film transistors are built on the glass substrate;

depositing a protection layer over the transparent electrodes;

patterning the transparent electrodes and the protection layer to form pixel patterns;

spin coating a photoresist layer over the protection layer using polymer resin material;

removing the photoresist layer over non-patterned areas; and  
depositing a reflective metal film over the photoresist layer retained on the glass substrate;

wherein after the protection layer is deposited over the transparent electrodes, the protection layer shields undesired reflection light during an exposure stage and reduces the exposure time.

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28. (new) The method as claimed in claim 27, wherein the protection layer is metal material.

29. (new) The method as claimed in claim 27, wherein the protection layer is non-metal material.